

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Appl. No. : 10/823,970)	Confirmation No. 5318
Applicant : OGAWA, et al.)	
Filed : 13 April 2004)	
Art Unit : 2892)	
Examiner : Hoang, Quoc Dinh)	
Attorney :)	
Docket No. : SPSN-AF01215)	
)	
For: SEMICONDUCTOR DEVICE HAVING)	
A PAD METAL LAYER AND A LOWER METAL)	
LAYER THAT ARE ELECTRICALLY)	
COUPLED, WHEREAS APERTURES ARE)	
FORMED IN THE LOWER METAL LAYER)	
BELOW A CENTER AREA OF THE PAD)	
METAL LAYER)	

Honorable Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE TO OFFICE ACTION

Dear Sir:

In response to the final Office Action dated December 8, 2008, Applicants respectfully request reconsideration of the above-identified patent application. Please consider the following amendments and remarks for allowance of the above-identified patent application.

I hereby certify that this correspondence
is being electronically transmitted to the
USPTO via EFS on the date shown below:
December 16, 2008
/Christina Holland/
Christina Holland